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Effective optical properties of absorbing nanoporous and nanocomposite thin films

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## **[Effective optical properties of absorbing nanoporous](http://dx.doi.org/10.1063/1.2402327) 1 [and nanocomposite thin films](http://dx.doi.org/10.1063/1.2402327) 2**

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accourage of such materials are derived nomi prevolusiv repreted and previous<br>averaging theory (VAT) to Maxwell's equations. The transmittance and reflectance<br>averaging theory (VAT) to Maxwell's equations. The transmittan This paper aims at developing numerically validated models for predicting the through-plane effective index of refraction and absorption index of nanocomposite thin films. First, models for the effective optical properties of such materials are derived from previously reported analysis applying the volume averaging theory (VAT) to Maxwell's equations. The transmittance and reflectance of nanoporous thin films are computed by solving Maxwell's equations and the associated boundary conditions at all interfaces using finite element methods. The effective optical properties of the films are retrieved by minimizing the root mean square of the relative errors between the computed and theoretical transmittance and reflectance. Nanoporous thin films made of  $SiO<sub>2</sub>$  and  $TiO<sub>2</sub>$  consisting of cylindrical nanopores and nanowires are investigated for different diameters and various porosities. Similarly, electromagnetic wave transport through dielectric medium with embedded metallic nanowires are simulated. The numerical results are compared with predictions from widely used effective property models including (1) the Maxwell-Garnett theory, (2) the Bruggeman effective medium approximation, (3) the parallel, (4) series, (5) Lorentz-Lorenz, and (6) the VAT models. Very good agreement is found with the VAT model for both the effective index of refraction and absorption index. Finally, the effect of volume fraction on the effective index of refraction and absorption index predicted by the VAT model is discussed. For certain values of wavelengths and volume fractions, the effective index of refraction or absorption index of the composite material can be smaller than that of both the continuous and dispersed phases. These results indicate guidelines for designing nanocomposite materials with desired optical properties. © *2006 American Institute of Physics.* [DOI: 10.1063/1.2402327] **9 10 11 12 13 14 15 16 17 18 19 20 21 22 23 24 25 26 27 28**

**29**

### **I. INTRODUCTION 30**

In recent years, synthesis and characterization of nano-**32** composite thin films in general and nanoporous in particular, **33** have been the subject of intense study.<sup>1-4</sup> Potential applica-**34** tions include dye-sensitized solar cells,<sup>5–7</sup> low-k dielectric materials,  $8,9$  $8,9$  biosensors,  $10-12$  and optical devices including waveguides,<sup>13–[15](#page-9-8)</sup> Bragg reflectors and Fabry-Perot **37** filters.<sup>16[–22](#page-9-10)</sup> For example, in order to confine and propagate **38** electromagnetic waves within a waveguide, the guide region **39** itself must have a higher index of refraction than the sur-40 rounding cladding.<sup>23</sup> On the other hand, Bragg reflectors and Fabry-Perot filters are built by generating alternating layers **41 42** with prescribed thickness and index of refraction. This ge-43 ometry uses constructive and destructive interferences to se-44 lectively reflect or transmit at desired wavelengths. In each 45 of these optical applications, the index of refraction is tuned 46 by controlling the morphology and porosity of the nanosize 47 pores formed by electrochemical etching of silicon, for ex-48 ample. Optimizing the performance of a given component 49 requires accurate knowledge of the effect of porosity, pore **31 35 36**

shape and size as well as the optical properties of each phase **50** on the effective optical properties of the nanocomposite me-**51** dium. **52**

Various effective property models have been proposed in **53** the literature and were discussed in our previous study.<sup>24</sup> In 54 brief, the Maxwell-Garnett theory (MGT)<sup>[25](#page-9-13)</sup> was first devel- 55 oped to model the effective electric permittivity of heteroge-**56** neous media consisting of monodispersed spheres arranged **57** in a cubic lattice structure within a continuous matrix and of **58** diameter much smaller than the wavelength of the incident **59** electromagnetic (EM) wave. Then, the effective dielectric 60 constant  $\varepsilon_{r,eff}$  is expressed as **61**

$$
\varepsilon_{r,\text{eff}} = \varepsilon_{r,c} \left[ 1 - \frac{3\phi(\varepsilon_{r,c} - \varepsilon_{r,d})}{2\varepsilon_{r,c} + \varepsilon_{r,d} + \phi(\varepsilon_{r,c} - \varepsilon_{r,d})} \right],\tag{1}
$$

where  $\varepsilon_{r,c}$  and  $\varepsilon_{r,d}$  are the dielectric constant of the continu- 63 ous and dispersed phases, respectively, while  $\phi$  is the poros- 64 ity. For dispersed phase volume fractions larger than  $\pi/6$  65  $\approx$  52% and polydispersed spheres the Bruggeman<sup>26</sup> model 66 **67**

**AQ: #1**

<span id="page-1-0"></span>a)Telephone: (310)-206-5598; Fax: (310)-206-4830. Electronic mail: gives the following implicit equation for  $\varepsilon_{r,\text{eff}}$ : pilon@seas.ucla.edu

<span id="page-2-0"></span>
$$
1 - \phi = \frac{\left(\frac{\varepsilon_{r,\text{eff}}}{\varepsilon_{r,c}} - \frac{\varepsilon_{r,d}}{\varepsilon_{r,c}}\right)}{\left[\left(\frac{\varepsilon_{r,\text{eff}}}{\varepsilon_{r,c}}\right)^{1/3} \left(1 - \frac{\varepsilon_{r,d}}{\varepsilon_{r,c}}\right)\right]}.
$$
(2)

69 On the other hand, the Lorentz-Lorenz model gives the ef-**70** fective index of refraction  $n_{\text{eff}}$  as

$$
\left(\frac{n_{\text{eff}}^2 - 1}{n_{\text{eff}}^2 + 2}\right) = (1 - \phi) \left(\frac{n_c^2 - 1}{n_c^2 + 2}\right) + \left(\varphi \frac{n_d^2 - 1}{n_d^2 + 2}\right),\tag{3}
$$

**72** where  $n_c$  and  $n_d$  are the index of refraction of the continuous 73 and dispersed phases, respectively. Alternatively, the parallel **74** model gives the effective property  $\psi_{\text{eff}}$  as a linear function of 75 the properties of the continuous and dispersed phases, i.e.,

$$
\mathbf{76} \qquad \psi_{\rm eff} = (1 - \phi)\psi_c + \phi\psi_d. \tag{4}
$$

77 The series model, on the other hand, is expressed as

$$
\frac{1}{\psi_{\text{eff}}} = \frac{1 - \phi}{\psi_c} + \frac{\phi}{\psi_d}.
$$
 (5)

**79** In addition, del Rio *et al.*<sup>27</sup> suggested the following effective **80** model for electrical conductivity based on the reciprocity 81 theorem

82 
$$
\sigma_{\text{eff}} = \sigma_c \frac{1 + \phi(\sqrt{\sigma_c/\sigma_d} - 1)}{1 + \phi(\sqrt{\sigma_d/\sigma_c} - 1)}.
$$
 (6)

83 Recently, del Rio and Whitaker<sup>28,29</sup> applied the volume av-84 eraging theory (VAT) to Maxwell's equations for an en-**85** semble of dispersed domains of arbitrary shape in a continu-86 ous matrix. They predicted the effective dielectric constant **87**  $\varepsilon_{r,\text{eff}}$ , relative permeability  $\mu_{r,\text{eff}}$ , and electrical conductivity **88**  $\sigma_{\text{eff}}$  of a two-phase mixture as<sup>28</sup>

$$
\mathbf{89} \qquad \varepsilon_{r,\text{eff}} = (1 - \phi)\varepsilon_{r,c} + \phi \varepsilon_{r,d},\tag{7}
$$

90 
$$
1/\mu_{r,eff} = (1 - \phi)/\mu_{r,c} + \phi/\mu_{r,d},
$$
 (8)

<span id="page-2-1"></span>
$$
\mathbf{91} \qquad \sigma_{\rm eff} = (1 - \phi)\sigma_c + \phi\sigma_d. \tag{9}
$$

 The range of validity of these expressions was discussed in details, and a set of inequalities to be satisfied was developed 94 by del Rio and Whitaker.<sup>28</sup> Their model has been numeri- cally validated by Braun and Pilon<sup>24</sup> for the effective through-plane index of refraction of *nonabsorbing* nano- porous media with open and closed cylindrical nanopores of various shapes and sizes corresponding to a wide range of porosity. The other models, however, underpredicted the nu-100 merical results.<sup>24</sup>

Moreover, validation of the above models against experi-102 mental data often yields contradictory results.<sup>30</sup> These con-103 tradictions can be attributed to the fact that first, some of 104 these models were not developed for the index of refraction 105 but for the dielectric constant. However, they have been used 106 for optical properties (e.g., Refs. [8,](#page-9-3) [9,](#page-9-4) [31,](#page-9-19) and [13](#page-9-7)). Second, **107** unlike the present study, some of these models have also **108** been derived by considering a unit cell containing one pore 109 with uniform incident electromagnetic fields thus ignoring **110** possible interference taking place between adjacent 111 pores.<sup>[25](#page-9-13)[,26,](#page-9-14)[32](#page-9-20)</sup> Finally, large experimental uncertainty may ex-**101**

ist in the measure of the porosity and the retrieval of the **112** complex index of refraction from transmittance and reflec-**113** tance measurements. The latter is very sensitive to the sur-**114** face roughness of the film and to the uniformity and value of **115** the film thickness. Unfortunately, often, neither the film **116** thickness  $L$  nor the experimental uncertainty for both  $\phi$  and 117  $m_{\text{eff}}$  are reported. **118**

citive property  $\psi_{\text{eff}}$  as a linear function of<br>
tric medium with embedded metallic<br>
continuous and dispersed phases, i.e., then are anisotropic and this tudy fo<br>  $+\phi \phi_{\ell A}$ . (4) the direction normal transmittance and The present study extends our previous investigation to **119** *absorbing* nanocomposite thin films. It aims at modeling **120** both the through-plane effective index of refraction and ab-**121** sorption index of (1) nanoporous thin films consisting of 122 horizontally aligned cylindrical nanopores or nanowires with **123** different diameters and various porosities and of (2) dielec- 124 tric medium with embedded metallic nanowires. Such thin **125** films are anisotropic and this study focuses on properties in **126** the direction normal to the film surface. It is limited to non-**127** magnetic materials for which  $\mu_{r,c} = \mu_{r,d} = \mu_{r,\text{eff}} = 1$ . Spectral **128** normal-normal transmittance and reflectance are obtained by **129** numerically solving Maxwell's equations and used to re-**130** trieve the effective index of refraction and absorption index. **131** The numerical results are then compared with previously re-**132** viewed models. Finally, the VAT model is analyzed in de-**133** tails. **134**

**II. ANALYSIS**

#### **135**

#### **A. Optical properties from volume averaging theory 136**

The index of refraction *n* and the absorption index *k* of **137** homogeneous media can be expressed in terms of the real **138** part of their dielectric constant  $\varepsilon_r$  and of their electrical con- **139** ductivity  $\sigma$  as<sup>23</sup> **140**

$$
n^2 = \frac{1}{2} \left[ \varepsilon_r + \sqrt{\varepsilon_r^2 + \left( \frac{\lambda \sigma}{2 \pi c_0 \varepsilon_0} \right)^2} \right],
$$
 (10) 141

$$
k^2 = \frac{1}{2} \left[ -\varepsilon_r + \sqrt{\varepsilon_r^2 + \left( \frac{\lambda \sigma}{2 \pi c_0 \varepsilon_0} \right)^2} \right],
$$
 (11) 142

where  $\lambda$  is the wavelength of incident radiation,  $c_0$  is the **143** speed of light in vacuum, and  $\varepsilon_0$  is the permittivity of free **144** space. The expression derived by Del Rio and Whitaker<sup>28</sup> for 145 the effective dielectric constant  $\varepsilon_{r,\text{eff}}$  and electrical conduc- **146** tivity  $\sigma_{\text{eff}}$  of a two-phase medium [Eqs. ([7](#page-2-0)) and ([9](#page-2-1))] can be **147** used to derive the effective optical properties of a two-phase **148** nanocomposite material **149**

<span id="page-2-2"></span>
$$
n_{\text{eff}}^2 = \frac{1}{2} [A + \sqrt{A^2 + B^2}], \tag{12}
$$

<span id="page-2-3"></span>
$$
k_{\text{eff}}^2 = \frac{1}{2} [-A + \sqrt{A^2 + B^2}], \tag{13}
$$

where

$$
A = \varepsilon_{r, \text{eff}} = \phi(n_d^2 - k_d^2) + (1 - \phi)(n_c^2 - k_c^2)
$$
 (14) 153

and

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154
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**152**

<span id="page-3-4"></span>**155** 
$$
B = \frac{\lambda \sigma_{\text{eff}}}{2 \pi c_0 \epsilon_0} = 2n_d k_d \phi + 2n_c k_c (1 - \phi). \tag{15}
$$

 In particular, when the dispersed phase is vacuum,  $\varepsilon_{r,d} = n_d$  = 1, and  $k_d = \sigma_d = 0$ . Note also that, unlike other effective property models, the above VAT models for  $n_{\text{eff}}$  and  $k_{\text{eff}}$  de-159 pend on both the real and complex parts of the complex 160 indices of refraction of the dispersed and continuous phases. In other words,  $R_{\text{calc}}$  and  $k_d$  affect not only  $k_{\text{eff}}$  but also  $n_{\text{eff}}$ .

#### 162 B. Governing equations and numerical **implementation 163**

lop the numerical model, let us first con-<br>  $|\pi_x|_{\text{avg}}(x,y) = -\frac{1}{2} \text{Re}\{E_z H_y^*\}$ <br>
revivionment (medium 1,  $n_1$ ,  $k_1 = 0$ ) from<br>
preside wave is incident on an absorbing<br>  $2, n_2$ ,  $k_2$ ) deposited onto an absorbing<br>  $2,$ In order to develop the numerical model, let us first con-**165** sider a surrounding environment (medium 1,  $n_1$ ,  $k_1=0$ ) from 166 which an electromagnetic wave is incident on an absorbing **167** thin film (medium 2,  $n_2$ ,  $k_2$ ) deposited onto an absorbing **168** dense substrate (medium 3,  $n_3$ ,  $k_3$ ). A linearly polarized 169 plane wave in transverse electric (TE) mode is incident nor-170 mal to the film top surface and propagates through the two-**171** dimensional thin film along the  $x$  direction. As the wave 172 propagates in the *x*-*y* plane, it has only one electric field **173** component in the  $z$  direction, while the magnetic field has 174 two components in the *x*-*y* plane (i.e., perpendicularly polar-175 ized), such that in a general time-harmonic form **164**

<span id="page-3-2"></span>**176** 
$$
\vec{E}(x, y, t) = E_z(x, y)e^{i\omega t}\vec{e}_z,
$$
  
\n**177**  
\n**178**  $\vec{H}(x, y, t) = [H_x(x, y)\vec{e}_x + H_y(x, y)\vec{e}_y]e^{i\omega t}.$  (16)

**179** Here,  $\vec{E}$  is the electric field vector,  $\vec{H}$  is the magnetic field **180** vector,  $\vec{e}_x$ ,  $\vec{e}_y$ , and  $\vec{e}_z$  are the unit vectors, and  $\omega = 2\pi c_0 / \lambda$  is 181 the angular frequency of the wave. For general time-varying 182 fields in a conducting medium, Maxwell's equations can be 183 written as

$$
\nabla \times \left[ \frac{1}{\mu_r \mu_0} \nabla \times \vec{E}(x, y, t) \right] - \omega^2 \varepsilon_r^* \varepsilon_0 \vec{E}(x, y, t) = 0, \quad (17)
$$

$$
\nabla \times \left[ \frac{1}{\varepsilon_r^* \varepsilon_0} \nabla \times \vec{H}(x, y, t) \right] - \omega^2 \mu_r \mu_0 \vec{H}(x, y, t) = 0, \quad (18)
$$

**186** where  $\mu_0$  and  $\mu_r$  are the magnetic permeability of vacuum 187 and the relative magnetic permeability, respectively, while **188**  $\varepsilon_r^*$  (= $n^2 - k^2 - i2nk$ ) is the complex dielectric constant. The 189 associated boundary conditions are

<span id="page-3-3"></span>**190** 
$$
\vec{n} \times (\vec{H}_1 - \vec{H}_2) = 0
$$
 (19)

191 at the surroundings-film interface,

$$
\vec{n} \times \vec{H} = 0 \tag{20}
$$

193 at symmetry boundaries,

<span id="page-3-0"></span>
$$
194 \qquad \sqrt{\mu_r \mu_0} (\vec{n} \times \vec{H}) + \sqrt{\varepsilon_0 \varepsilon_r^*} \vec{E} = 0 \tag{21}
$$

**195** at the film-substrate interface, and

<span id="page-3-1"></span>
$$
\mathbf{196} \qquad \sqrt{\mu_0 \mu_r} (\vec{n} \times \vec{H}) + \sqrt{\varepsilon_0 \varepsilon_r^*} \vec{E} = 2 \sqrt{\varepsilon_0 \varepsilon_r^*} \vec{E}_0, \tag{22}
$$

**197** at the source surface, where  $\vec{n}$  is the normal vector to the 198 appropriate interface. Equation ([21](#page-3-0)) corresponds to the im**211**

pedance boundary condition for a semi-infinite substrate **199** while Eq. ([22](#page-3-1)) is the low reflecting boundary condition to **200** model the imaginary source surface where the incident elec-**201** tromagnetic wave  $E_0 = E_0 \vec{e}_z$  is emitted and that is transparent **202** to the reflected waves. **203**

Moreover, the Poynting vector  $\vec{\pi}$  is defined as the cross **204** product of the electric and magnetic vectors,  $\vec{\pi} = \frac{1}{2}Re\{\vec{E} \text{ 205}$ →  $\times \vec{H}$ . Its magnitude corresponds to the energy flux carried 206 by the propagating electromagnetic wave. Averaging the *x* **207** component of the Poynting vector at location  $(x, y)$  over a **208** period  $2\pi/\omega$  of the EM wave gives<sup>23</sup> **209**

$$
|\pi_x|_{\text{avg}}(x, y) = -\frac{1}{2} \text{Re}\{E_z H_y^*\}\
$$

and

$$
|\pi_{y}|_{\text{avg}}(x, y) = \frac{1}{2} \text{Re}\{E_{z}H_{x}^{*}\}.
$$
 (23)

The  $H_x(x, y)\vec{e}_x + H_y(x, y)\vec{e}_y$  incident electric field  $\vec{E}_0 = E_{0z}\vec{e}_z$  213 and, therefore, the incident time-averaged Poynting vector **214**  $|\vec{\pi}_0|_{\text{avg}}$  are imposed at all locations along the source surface. **215** The values of the *x* component of the Poynting vector along **216** the film-substrate interface are then calculated numerically **217** and averaged along the boundary to yield  $|\pi_{x,t}|_{avg}$ . The trans- 218 mittance of the thin film is then recovered by taking the ratio **219** of the transmitted film to the incident average Poynting vec-**220** tors, i.e.,  $T_{\text{num}} = |\pi_{x,t}|_{\text{avg}} / |\pi_{x,0}|_{\text{avg}}$ . Similarly, the magnitude of **221**  $\frac{\text{AG:}}{\text{#2}}$ the *x* component of the reflected time-averaged Poynting **222** vector  $|\pi_{x,r}|_{avg}$  is computed numerically, and the reflectance **223** of the film is computed according to  $R_{\text{num}} = |\pi_{x,r}|_{\text{avg}} / |\pi_{x,0}|_{\text{avg}}$ . **224** 

Finally, the above equations were solved numerically us-**225** ing a commercially available finite element solver (FEMLAB 226 3.0) applying the Galerkin finite element method on unstruc- 227 tured meshes. The two-dimensional (2D) Maxwell equations **228** are solved in the frequency domain using a 2D transverse **229** electric (TE) wave formulation as described by Eq. ([16](#page-3-2)). In **230** particular, the discretization uses second-order elements to **231** solve for the electric field.<sup>33</sup> **232**

In order to validate the numerical implementation of this **233** system of equations, a system composed of a dense absorb-**234** ing thin film  $(n_2=1.7, k_2)$  of thickness *L* deposited on a per- 235 fectly reflective substrate  $(n_3 = k_3 \rightarrow \infty)$  in air  $(n_1 = 1, k_1 = 0)$  236 was simulated. The value of  $k_2$  was varied over three orders **237** of magnitude from 0.001 to 1, and the infinitely large optical **238** constants of the substrate were imposed as  $n_3 = k_3 = 10^6$ . Nor- 239 mal reflectivity of the system was computed and plotted as a **240** function of  $\pi L/\lambda$ .<sup>[30](#page-9-18)</sup> The numerical solutions match the ana- **241** lytical solutions found in Ref. [23,](#page-9-11) for example. **242**

Figure [1](#page-4-0) schematically shows the geometry of the simu-**243** lated nanocomposite thin film on a semi-infinite substrate. **244** The Maxwell equations are solved in both phases separately **245** as previously described. Equation ([19](#page-3-3)) is used as the bound- 246 ary condition not only at the incident vacuum-film interface **247** but also at all continuous/dispersed phase interfaces. Figure [1](#page-4-0) **248** is a schematic representation of an actual model consisting of **249** three nanopores or nanowires of diameter *D*=10 nm and cell **250** width *H* of 20 nm corresponding to a volume fraction  $\phi$  251  $=\pi D^2 / 4H^2 = 0.1963$  $=\pi D^2 / 4H^2 = 0.1963$  $=\pi D^2 / 4H^2 = 0.1963$ . Figure 1 also indicates material proper- **252** 

<span id="page-4-0"></span>

FIG. 1. Schematic of the physical model and the corresponding finite element grid of the absorbing nanoporous thin film along with the boundary conditions.

253 ties of the different domains and the locations at which each **254** of the boundary conditions are applied. Note that the lines 255 separating two adjacent cubic cells do not correspond to an 256 actual boundary conditions.

Finally, it is important to note that Maxwell's equations 258 are generally applied to macroscopic averages of the fields **259** which can vary widely in the vicinity of individual atoms **260** where they undergo quantum mechanical effects. In addition, 261 both the matrix and the nanodomains are treated as homoge-**262** neous and isotropic with index of refraction *n* and absorption **263** index *k* equal to that of the bulk. **257**

#### **III. RETRIEVAL OF EFFECTIVE COMPLEX INDEX OF 264 REFRACTION 265**

The effective complex index of refraction of the nano-**267** composite thin film was retrieved by minimizing the root **268** mean square of the relative error for the transmittance  $\delta T$  and **269** reflectance  $\delta R$  defined as **266**

and

 $(24)$ 

<span id="page-4-1"></span>
$$
\delta T^2 = \frac{1}{N} \sum_{i=1}^{N} \left[ \frac{T_{\text{calc}}(\lambda_i) - T_{\text{num}}(\lambda_i)}{T_{\text{num}}(\lambda_i)} \right]^2
$$

**270 271**

**272**

$$
\delta R^2 = \frac{1}{N} \sum_{i=1}^{N} \left[ \frac{R_{\text{calc}}(\lambda_i) - R_{\text{num}}(\lambda_i)}{R_{\text{num}}(\lambda_i)} \right]^2,
$$

 where  $T_{\text{num}}(\lambda_i)$  and  $R_{\text{num}}(\lambda_i)$  are the transmittance and reflec- tance computed numerically using FEMLAB 3.0 while  $T_{\text{calc}}(\lambda_i)$  and  $R_{\text{calc}}(\lambda_i)$  are the transmittance and reflectance predicted from the electromagnetic wave theory at *N* different wave-lengths  $\lambda_i$  between 400 and 900 nm.

In predicting the theoretical transmittance  $T_{\text{calc}}$  and re- flectance  $R_{\text{calc}}$  from the EM wave theory, polarization effects are disregarded since (1) the incident EM wave is normal to the surface, i.e., the plane of incidence is not defined and the components of the polarization cannot be distinguished $^{23}$  and (2) scattering is neglected as the nanopores or nanowires are much smaller than the wavelength of the EM wave. In addi-285 tion, nonlinear optical effects are neglected and surface **278**

**301**

**323**

waves are not observed in the current situation as resonance **286** modes were not excited for the materials and wavelengths **287** considered. Finally, we assume that all interfaces are opti-**288** cally smooth, i.e., surface roughness is much smaller than the **289** wavelength of the incident EM wave. This assumption may **290** not be satisfied in practice and scattering by the sometimes **291** rough film surface can be observed.<sup>34</sup> **292**

The Microsoft Excel Solver based on the generalized **293** reduced gradient nonlinear optimization method<sup>37</sup> was used 294 to identify the optimum  $n_{\text{eff}}$  and  $k_{\text{eff}}$  that minimizes the root **295** mean square  $\delta T$  and  $\delta R$ . The theoretical transmittance and **296** reflectance for homogeneous thin films under normal inci-**297** dence are expressed as<sup>38</sup> **298**

<span id="page-4-2"></span>
$$
T_{\text{calc}}(\lambda) = \frac{\tau_{12}\tau_{23}e^{-\kappa_2 L}}{1 + 2r_{12}r_{23}e^{-\kappa_2 L}\cos(\delta_{12} + \delta_{23} - \zeta_2) + r_{12}^2r_{23}^2e^{-2\kappa_2 L}},\tag{25)
$$

$$
R_{\rm calc}(\lambda) = \frac{r_{12}^2 + 2r_{12}r_{23}e^{-\kappa_2 L}\cos(\delta_{12} + \delta_{23} - \zeta_2) + r_{23}^2e^{-2\kappa_2 L}}{1 + 2r_{12}r_{23}e^{-\kappa_2 L}\cos(\delta_{12} + \delta_{23} - \zeta_2) + r_{12}^2r_{23}^2e^{-2\kappa_2 L}},\tag{26)
$$

where

$$
r_{ij}^2 = \frac{(n_i - n_j)^2 + (k_i - k_j)^2}{(n_i + n_j)^2 + (k_i + k_j)^2}, \quad \tau_{ij} = \frac{n_i}{n_j} \frac{4(n_i^2 + k_i^2)}{(n_i + n_j)^2 + (k_i + k_j)^2}, \quad \textbf{302}
$$

<span id="page-4-3"></span>
$$
\tan \delta_{ij} = \frac{2(n_ik_j - n_jk_i)}{n_i^2 + k_i^2 - (n_j^2 + k_j^2)}, \ \ \kappa_2 = 4\pi k_2/\lambda, \text{ and}
$$
\n303

\n(27)

$$
\zeta_2 = 4 \pi n_2 / \lambda. \tag{27}
$$

Len, 2k,<br>  $\mathbf{E} = \mathbf{F} \mathbf{F$ Here, the subscripts 1 and 3 refer to the media above and **306** below the nanocomposite thin film treated as an effective **307** homogeneous and referred to by subscript 2. Validation of **308** the retrieval method combined with the numerically com-**309** puted transmittance was performed by simulating a dense **310** silicon absorbing thin film of thickness  $L = 1$   $\mu$ m surrounded **311** on both sides by vacuum  $(n_1=n_3=1.0, k_1=k_3=0.0)$  and hav- **312** ing a constant complex index of refraction  $m_2 = n_2 - ik_2 = 3.5$  313 −i0.01 over the spectral interval from 440 to 1700 nm. The **314** values of  $n_2$  and  $k_2$  retrieved with the above mentioned op- **315** timization method fall within  $9.0 \times 10^{-6}$ % and 0.06% of the **316** input values, respectively. Therefore, both the numerical **317** simulation tool and the inverse method to retrieve the effec-**318** tive complex index of refraction of nanocomposite thin films **319** from transmittance and reflectance calculations have been **320** validated and can now be used. **321**

#### **IV. RESULTS AND DISCUSSION 322**

#### **A. Absorbing nanoporous media**

Simulations of electromagnetic wave transport in nano-**324** porous absorbing SiO<sub>2</sub> thin film were conducted for various 325 porosities, film thicknesses, and pore shapes and sizes. First, **326** the continuous phase was assumed to be characterized by **327** constant optical properties  $n_c = 1.44$  and  $k_c = 0.01$  over the **328** spectral range from 400 to 900 nm while  $n_d=n_1=1.0$ ,  $k_d$  329  $=k_1=k_3=0.0$ , and  $n_3=3.39$ . The optimization method previ- **330** 

<span id="page-5-0"></span>

FIG. 2. Evolution of the through-plane effective index of refraction and absorption index of nanoporous  $SiO<sub>2</sub>$  thin films as a function of  $L/D$  for films with 19.63*%* porosity and pore diameters of 10 and 100 nm.

ously described was used to retrieve the through-plane effec- tive index of refraction  $n_{\text{eff}}$  and absorption index  $k_{\text{eff}}$  from the numerically computed transmittance. A numerically con-334 verged solution was obtained with more than 50,000 triangu- lar meshes for 250 wavelengths with a 2 nm increment. The pore diameter was 10 or 100 nm while the ratio of the film thickness *L* to pore diameter *D* varied from 10 to 200. Fi- nally, for a given pore diameter, the porosity  $\phi$  varied from 0.0 to 0.7 by changing the dimensions of the cubic cells. **331**

Figure [2](#page-5-0) shows the evolution of the through-plane effec- tive index of refraction  $n_{\text{eff}}$  and absorption index  $k_{\text{eff}}$  as func- tions of the ratio  $L/D$  for a porosity  $\phi$  equal to 0.1963. The thick solid line corresponds to the predictions of the VAT models given by Eqs. ([12](#page-2-2)) and ([13](#page-2-3)). The data points repre- sent the values retrieved from the numerically computed transmittance by minimizing  $\delta T$ . As established for nonab- sorbing thin films,<sup>24</sup> the effective index of refraction  $n_{\text{eff}}$  as well as the effective absorption index  $k_{\text{eff}}$  become indepen- dent of both the film thickness and the pore diameter for **340**

<span id="page-5-1"></span>

FIG. 3. Root mean square  $\delta T$  as calculated according to Eq. ([24](#page-4-1)) as a function of *L*/*D*.

thick enough films corresponding to  $L/D > 100$  in the cases investigated. In addition, for porosity  $\phi = 0.1963$ , the VAT 351 model predicts the retrieved values of  $n_{\text{eff}}$  and  $k_{\text{eff}}$  for  $L/D$  352 = 200 within 0.13*%* and 0.075*%*, respectively. Finally, Fig. [3](#page-5-1) **353** shows the root mean square  $\delta T$  as a function of the ratio **354**  $L/D$ . The value of  $\delta T$  remains small and decreases as the **355** film thickness increases due to smoother interference fringes. **356** It also decreases as the bubble diameter decreases thanks to **357** reduction in scattering by the bubbles. For most cases (ex-358) cept for  $L/D < 20$  and  $D = 100$ nm), the numerical and calcu- 359 lated transmittances  $T_{\text{num}}$  and  $T_{\text{calc}}$  plotted for wavelengths **360** between 400 and 900 nm are undistinguishable. For ex-**361** ample, for  $D = 10$ nm,  $L/D = 150$ , and  $\phi = 0.3$ , the maximum **362** relative error  $|T_{\text{num}} - T_{\text{calc}}| / T_{\text{num}}$  is 0.07% while  $\delta T$  is equal to 363 2.04 × 10<sup>-4</sup>. Note also that (i) all numerical results were con- **364** verged, i.e., independent of the number of meshes and (ii) the **365** root mean square remains relative small. Thus, the large **366** variations in  $n_{\text{eff}}$  and  $k_{\text{eff}}$  observed for small values of  $L/D$  367 are attributed to interferences between nanopores whose ef-**368** fect tend to average out once enough pores are considered. **369** Then, beyond a critical film thickness to pore diameter ratio, **370** the medium behaves as homogeneous with some effective **371** properties. **350 372**

Moreover, Fig. 4 compares the predictions of various **373** effective medium approaches applied to the through-plane **374** effective index of refraction  $n_{\text{eff}}$  and absorption index  $k_{\text{eff}}$  of **375** nanoporous thin films as a function of porosity for *nc* **376**  $= 1.44, k_c = 0.01, n_d = 1.0, k_d = 0.0, D = 10 \text{ nm},$ = 150. Note that the series and reciprocity models cannot be **378** computed for  $k_{\text{eff}}$  because  $k_d$ =0.0. As intuitively expected, **379** *n*eff and *k*eff decrease as the porosity increases. Overall, good **380** agreement is found between the VAT model and the numeri-**381** cal results while the parallel, series, Maxwell-Garnett, and **382** reciprocity models applied to  $n_{\text{eff}}$  and  $k_{\text{eff}}$  underpredict the **383** numerical values. The same conclusions were obtained when **384** considering the effective index of refraction of *nonabsorbing* **385** nanoporous thin films.<sup>24</sup> Note that the values of  $n_{\text{eff}}$  predicted **386** by the Lorentz-Lorenz equation [Eq. ([39](#page-8-1))] fell within 0.2% 387 of the predictions of the Maxwell-Garnett model and, there-**388** fore, were omitted in Fig. [4](#page-6-0) for the sake of clarity. In addi-**389** and *L*/D **377** 

<span id="page-6-0"></span>

FIG. 4. Evolution of the through-plane effective index of refraction and absorption index as a function of porosity for nanoporous thin films with  $n_c = 1.44$ ,  $k_c = 0.01$ ,  $n_d = 1.0$ ,  $k_d = 0.0$ ,  $D = 10$  nm, and  $L/D = 150$ .

 tion, when the pores are open and consist of a set of alter- nating columns of dispersed and continuous phase, perpendicular to the substrate, the dielectric constant can be modeled using the parallel model given by Eq.  $(7)$ .<sup>30</sup> There- fore, the VAT model for both  $n_{\text{eff}}$  and  $k_{\text{eff}}$  provides an accu-395 rate prediction of the effective optical properties of the nano- porous thin films simulated with various pore sizes and 397 porosities. The other effective property models appear not to 398 be appropriate for the reasons previously discussed.

In addition, spectral calculations for nanoporous  $TiO<sub>2</sub>$ 400 over the spectral range from 400 to 900 nm have been per-401 formed for cylindrical nanopores and nanowires of diameter *D*= 10 nm and for porosity of 0.2146 as illustrated in Fig. [5.](#page-6-1) **402 403** The overall film thickness *L* was such that  $L/D = 150$  to en-404 sure that the heterogeneous thin film behaves as homoge-405 neous with some effective properties. The spectral depen-**406** dency of the complex index of refraction of bulk  $\text{TiO}_2$  was [40](#page-9-27)7 accounted for by fitting reported experimental data<sup>39,40</sup> with **399 AQ:**

408 a second-order polynomial to yield **#3**

<span id="page-6-1"></span>

FIG. 5. Morphology of simulated nanoporous with cylindrical nanopores (left) or nanowires (right) for  $\phi$ =0.2146.

$$
n_{c,\lambda} = 2.179 - 3.234 \times 10^{-4} \lambda + 7.967 \times 10^{-8} \lambda^2, \qquad (28) \; 409
$$

$$
k_{c,\lambda} = 8.501 \times 10^{-4} + 1.264 \times 10^{-5} \lambda - 9.362 \times 10^{-9} \lambda^2,
$$
\n(29) 410

where the wavelength  $\lambda$  is expressed in nanometers and var- $411$ ies between 400 and 900 nm. First, the transmittance and **412** reflectance computed for cylindrical pores embedded in a **413**  $TiO<sub>2</sub>$  matrix and for cylindrical  $TiO<sub>2</sub>$  nanowires (Fig. [5](#page-6-1)) were **414** found to be identical. This indicates that beyond a critical **415** film thickness, the pore shape has no effect on the effective **416** optical properties of the nanocomposite materials as found **417** by Braun and Pilon<sup>24</sup> for nonabsorbing nanoporous thin 418 films. Note that the top surface of the thin film is optically **419** smooth and the film surface roughness due to the presence of **420** nanowires is not accounted for. **421**

Finally, the theoretical transmittance and reflectance **422** were computed using Eqs.  $(25)$  and  $(27)$  for an homogeneous **423** thin film having effective spectral index of refraction and **424** absorption index predicted by the VAT model [Eqs. ([12](#page-2-2)) and 425 (15)]. Figure 6 shows good agreement between the numerical 426 and theoretical transmittances and reflectances of a nano-**427** porous TiO2 thin film of porosity 0.2146. The maximum ab-**428** solute errors in transmittance and reflectance were less than **429** 0.03*%* and 0.0065*%*, respectively, and an average relative **430** error less than 3.0*%*. This confirms the validity of the VAT **431** model on a spectral basis for the effective complex refraction **432** of nanoporous media consisting of cylindrical pores in an **433** absorbing matrix or of closely packed nanowires. **434**

#### **B. Dielectric medium with metallic nanowires 435**

This section aims at assessing the validity of the VAT **436** model for dielectric materials or fluids containing metallic **437** nanowires. Let us consider a dielectric continuous phase of **438** complex index of refraction  $m_c = 1.4 - i0.0$  containing gold 439 nanowires and having the same index of refraction as bulk **440** gold at 400 nm, i.e.,  $m_d = 1.66 - i1.96$ <sup>23</sup> Two nanowire diam- 441 eters *D* are considered namely 10 and 100 nm and, in all **442** cases, the overall film thickness *L* is such that *L*/*D*= 150. **443** Then, the film can be treated as homogeneous and effective **444** properties can be defined. **445**

<span id="page-7-0"></span>

FIG. 6. Comparison of theoretical and numerical spectral transmittance and reflectance of nanoporous  $TiO<sub>2</sub>$  with cylindrical nanopores and nanowires of diameter  $D=10$  nm and porosity  $\phi = 0.2146$  over the wavelength range between 400 and 900 nm and film thickness *L*= 150 D.

**EVALUAT THE COPY COPY AND CONSULTERATION** (**COPY AND COPY AND COPY AND COPY AND COPY AND COPY AND COPY COPY AND COPY AND COPY AND COPY COPY COPY COPY (<b>COPY AND COPY AND COPY AND COPY**  $\frac{1}{2}$  TO  $\frac{1}{2}$  TO  $\frac{1}{2}$ Figure [7](#page-7-1) compares the through-plane effective index of 447 refraction and absorption index of the nanocomposite me-448 dium retrieved from both numerical transmittance and reflec-449 tance with those predicted by the VAT model for volume **450** fraction of nanowires  $\phi$  ranging from 0.0 to 0.7. Note that 451 the retrieved effective optical properties were obtained by **452** minimizing  $\delta T + \delta R$  and were very sensitive to the initial **453** guess particularly for  $D = 100$  nm when transmittance was 454 very small. In those cases, the properties were retrieved by **455** minimizing only the root mean square  $\delta R$ . Overall, there 456 exist a relatively good agreement between the retrieved val-**457** ues of  $n_{\text{eff}}$  and  $k_{\text{eff}}$  at all nanowire volume fractions and for both *D*= 10 and 100 nm. The VAT model predicts the re-**458 459** trieved effective index of refraction  $n_{\text{eff}}$  within  $\pm 6.2\%$  and **460** the effective absorption index  $k_{\text{eff}}$  within  $\pm 2.9\%$ . The fact 461 that metallic nanowires have size dependent optical proper-462 ties has been ignored but can be accounted for provided that 463 these properties be measured independently. **446**

Moreover, it is interesting to note that the presence of a 465 strongly absorbing dispersed phase such as metallic nano-466 wires reduces dramatically the effective index of refraction **467** of the composite medium even for small volume fractions  $\phi$ . **468** For certain values of  $\phi$ , the effective index of refraction  $n_{\text{eff}}$ 469 is smaller than that of either the continuous or dispersed **470** phases, i.e.,  $n_{\text{eff}} \leq \text{Min}(n_c, n_d)$ . It also reaches a minimum at **471** the volume fraction  $\phi_1 = 0.25$  as discussed in detail in the 472 next section. Simultaneously, the effective absorption index 473 increases significantly even for small metallic nanowire vol-474 ume fractions. Note also that if the film is thick enough for 475 the effective medium approximation to be valid, the metallic 476 nanowires can take various shapes and/or sizes without af-477 fecting the above predictions. **464**

Finally, scattering by the nanopores and nanoparticles **479** can be neglected if their size is much smaller than the wave-**480** length of the incident radiation.<sup>41[,42](#page-9-29)</sup> A quantitative criterion **478**

<span id="page-7-1"></span>

FIG. 7. Comparison between the VAT model and numerically retrieved effective index of refraction and absorption index of dielectric medium  $(m_c)$  $= 1.4 - i0.0$ ) with embedded metallic nanowires  $(m_d = 1.66 - i1.96)$  for various volume fractions and nanowire diameter.

requires that the size parameter  $\chi = \pi D/\lambda$  be much smaller **481** than unity.<sup>41</sup> This assumption is typically valid for absorbing **482** nanocomposite materials and nanofluids in the visible and **483** infrared part of the spectrum. In the present study  $\chi$  varies **484** between 0.011 and 0.25. In estimating  $T_{\text{calc}}$  and  $R_{\text{calc}}$  from the **485** EM wave theory, the fraction of energy scattered by nanop-**486** ores or nanowires was neglected compared with that trans-**487** mitted and reflected by the film along the incident direction. **488** This assumption was confirmed numerically for all reported **489** results by comparing the magnitude of the *y* component of **490** the Poynting vector perpendicular to the incident directions **491** with its *x* component at all locations in the *x*-*y* plane, i.e., **492**  $|\pi_{y}|_{\text{avg}} \ll |\pi_{x}|_{\text{avg}}.$ **493**

### **C. Discussion of the effective VAT model**

The objective of this section is to mathematically ana-**495** lyze the now numerically validated expressions of  $n_{\text{eff}}$  and **496**  $k_{\text{eff}}$  given by Eqs. ([12](#page-2-2)) and ([13](#page-2-3)). Their derivatives with re- 497 spect to volume fraction  $\phi$  are expressed as **498**

$$
\frac{\partial n_{\text{eff}}^2}{\partial \phi} = \frac{1}{2} [\alpha + (A^2 + B^2)^{-1/2} (A \alpha + B \beta)],
$$
 (30) **499**

**494**

$$
500 \qquad \frac{\partial k_{\text{eff}}^2}{\partial \phi} = \frac{1}{2} \left[ -\alpha + (A^2 + B^2)^{-1/2} (A\alpha + B\beta) \right],\tag{31}
$$

**501** where

$$
\alpha = \frac{\partial A}{\partial \phi} = (n_d^2 - k_d^2) - (n_c^2 - k_c^2)
$$

**503** and

$$
\mathbf{504} \qquad \beta = \frac{\partial B}{\partial \phi} = 2(n_d k_d - n_c k_c). \tag{32}
$$

 Note that the derivatives of *A* and *B* with respect to porosity  $\phi$  denoted by  $\alpha$  and  $\beta$ , respectively, are independent of po- rosity. The effective properties  $n_{\text{eff}}$  and  $k_{\text{eff}}$  reach their maxi- mum or minimum when the first-order derivatives with re-spect to volume fraction vanish, i.e., when

<span id="page-8-2"></span>**510** 
$$
(A^{2} + B^{2})^{-1/2}(A \alpha + B \beta) = -\alpha
$$
 (33)

**511** and

<span id="page-8-3"></span>**512** 
$$
(A^2 + B^2)^{-1/2} (A\alpha + B\beta) = \alpha.
$$
 (34)

 Squaring both sides of Eqs. (33) and (34) yields the same second-order polynomial in terms of the volume fraction  $\phi$ . Given the complex index of refraction of both phases, one can solve for the critical volume fraction corresponding to a minimum and/or maximum of the effective index of refrac-518 tion and/or absorption index. After rearrangement two roots  $\phi_1$  and  $\phi_2$  can be found

$$
\phi_1 = \frac{2[(\alpha^2 - \beta^2)n_c k_c - \alpha\beta(n_c^2 - k_c^2)]}{\beta(\alpha^2 + \beta^2)},
$$
\n(35)

$$
\phi_2 = \frac{n_c k_c}{n_c k_c - n_d k_d}.
$$
\n(36)

 In order to know whether  $n_{\text{eff}}$  and  $k_{\text{eff}}$  reach their maximum or minimum, their second-order derivatives with respect to  $\phi$  have to be examined. Based on Eqs.  $(33)$  and  $(34)$ , the second-order derivatives of  $n_{\text{eff}}$  or  $k_{\text{eff}}$  are the same for  $\phi_1$ and  $\phi_2$  and can be expressed as

$$
\left. \frac{\partial^2 n_{\text{eff}}}{\partial \phi^2} \right|_{\phi_{1,2}} = \frac{1}{4n_{\text{eff}}} \frac{(A\beta - B\alpha)^2}{(A^2 + B^2)^{3/2}},
$$
(37)

**527**

**528**

$$
\left. \frac{\partial^2 k_{\text{eff}}}{\partial \phi^2} \right|_{\phi_{1,2}} = \frac{1}{4k_{\text{eff}}} \frac{(A\beta - B\alpha)^2}{(A^2 + B^2)^{3/2}}.
$$
\n(38)

**529** Since the terms on the right-hand side of the above two equa-**530** tions are always positive,  $n_{\text{eff}}$  and  $k_{\text{eff}}$  can only reach a mini-**531** mum.

However, for an arbitrary set of dispersed and continu-**533** ous phases, the values of  $\phi_1$  and  $\phi_2$  do not always fall in the **534** physically acceptable range of porosities between 0 and 1. **535** For positive values of the properties  $n_c$ ,  $n_d$ ,  $k_c$ , and  $k_d$ , one **536** can show that, unlike  $\phi_1$ , the second root  $\phi_2$  never falls between 0 and 1. **537 532**

Moreover, the following expressions can be used to **539** identify whether  $\phi_1$  is the solution of Eqs. ([33](#page-8-2)) or ([34](#page-8-3)), i.e., **540** whether  $n_{\text{eff}}$  or  $k_{\text{eff}}$  reach a minimum at  $\phi = \phi_1$ **538**

<span id="page-8-1"></span>
$$
\chi = \frac{n_d k_d - n_c k_c}{n_c k_c (n_d^2 - k_d^2) - n_d k_d (n_c^2 - k_c^2)}.
$$
\n(39) 541

If  $\chi$  is strictly positive then  $k_{\text{eff}}$  reaches a minimum while  $n_{\text{eff}}$  reaches a minimum if  $\chi$  is strictly negative. Neither  $n_{\text{eff}}$  nor  $k_{\text{eff}}$  reach a minimum if  $\chi = 0$ . In the case of nanoporous media,  $\chi$  and  $\phi_2$  are constant and equal to  $-1$  and 1, respec tively. Therefore  $n_{\text{eff}}$  can reach a minimum less than 1.0 at an acceptable  $\phi_1$ . Finally, for the dielectric medium with em bedded metallic nanowires simulated previously,  $\chi$  is strictly negative and *n*eff reaches a minimum. This is illustrated in **549** Fig. [7](#page-7-1) where  $n_{\text{eff}}$  reaches a minimum of 1.33 at  $\phi_1 = 0.25$ . **550**

Finally, this study constitutes the first two-dimensional **551** numerical validation for TE polarization of the VAT applied **552** to the three-dimensional Maxwell equations<sup>28[,29](#page-9-17)</sup> in two-phase **553** systems with dispersed domains of arbitrary shape. For com-**554** plete validation, the present study should be extended to both **555** a three-dimensional and transverse magnetic (TM) polariza- 556 tion cases. **557**

### **V. CONCLUSIONS**

*β*, respectively, are independent of pointing, unisolary considerable  $n_{eff}$  and  $k_{eff}$  reach their maxi-<br> **Properties**  $n_{eff}$  and  $k_{eff}$  reach the intere-dimensional Maxwell equals<br>
when the inst-order derivatives with The VAT models for the effective dielectric and electri-**559** cal properties of two-phase media28 have been used to derive **560** the through-plane effective index of refraction  $n_{\text{eff}}$  and ab- **561** sorption index *k*eff of nanoporous materials. Moreover, a nu-**562** merical scheme has been developed and implemented to **563** solve the Maxwell equations for a normally incident TE elec-**564** tromagnetic wave traveling through  $(1)$  nanoporous  $SiO<sub>2</sub>$  and **565** TiO<sub>2</sub> consisting of cylindrical pores or nanowires and (2) **566** dielectric medium containing cylindrical nanowires. All in-**567** terfaces were treated as optically smooth and the dispersed **568** phase volume fraction varied from 0.0 to 0.7. Calculations **569** were performed on a gray or spectral basis between 400 and **570** 900 nm. The effective optical properties for the simulated **571** nanocomposite thin films were retrieved by minimizing the **572** root mean square of the relative errors for the transmittance **573** and reflectance. In all cases, the results for both  $k_{\text{eff}}$  and  $n_{\text{eff}}$  **574** are in good agreement with the predictions from the VAT **575** model. Finally, the numerically validated VAT model is dis-**576** cussed and used to predict the behavior of the optical prop-**577** erties of nanocomposite materials. It shows that under certain **578** conditions, the effective index of refraction or absorption **579** index of the composite material can be smaller than that of **580** both the continuous and dispersed phases. The same results **581** and conclusions are expected for spherical pores and nano-**582** particles. These results can be used to design and optimize **583** nanocomposite materials with tunable optical properties. As **584** well as to measure the porosity or nanowire volume fraction **585** provided that the film be thick enough to be treated as ho-**586** mogeneous with some effective properties and that all sur-**587** faces be optically smooth. **588**

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**589**

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